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### **APPENDICES**

## Appendix A Ethylene Epoxidation over Alumina- and Silica-Supported Silver Catalysts in Low-Temperature AC Dielectric Barrier Discharge

**Table A1** Effect of plasma volume-to-catalyst weight ratio on  $C_2H_4$  and  $O_2$  conversions, and power consumption

Plasma volume-to- Conversio		ion (%)	Power consumption	tion (Ws x 10 <sup>16</sup> )	
catalyst weight ratio (cm <sup>3</sup> /g)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced	
Sole plasma	21.79	91.51	1.42	14.06	
0.81	15.16	33.72	1.92	17.10	
1.04	18.00	94.92	1.63	14.48	
1.55	12.71	59.74	2.57	12.41	
2.51	18.18	97.63	1.63	15.88	
3.78	22.90	82.06	1.40	18.67	

**Table A2**Effect of plasma volume-to-catalyst weight ratio on EO yield andselectivities for EO and other products

Plasma volume-to-	EQ	Selectivity (%)					
catalyst weight ratio (cm <sup>3</sup> /g)	(%)	EO	Ha	СО	C <sub>2</sub> H <sub>2</sub>		
Sole plasma	2.20	10.08	79.28	60.98	52.46		
0.81	1.70	11.24	29.71	17.84	35.23		
1.04	2.02	11.25	58.30	29.93	47.36		
1.55	2.63	20.73	82.23	61.70	77.01		
2.51	1.86	10.29	57.00	32.91	45.46		
3.78	1.72	7.50	47.78	36.76	32.79		

	Conversion (%)		Power consumption (Ws x 10 <sup>16</sup> )		
Ag loading (wt.%)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced	
Sole plasma	21.79	91.51	1.42	14.06	
0	25.49	97.68	1.03	17.33	
5	12.71	59.74	2.57	12.41	
10	9.28	57.69	3.50	14.07	
15	10.07	46.69	2.96	15.62	
20	9.96	58.03	3.25	15.54	

**Table A3** Effect of Ag loading on the  $Al_2O_3$  support on  $C_2H_4$  and  $O_2$  conversions, and power consumption

**Table A4** Effect of Ag loading on the  $Al_2O_3$  support on EO yield and selectivities for EO and other products

Ag loading (wt.%)	EO yield	Selectivity (%)					
	(%)	EO	H <sub>2</sub>	СО	$C_2H_2$		
Sole plasma	2.20	10.08	79.28	60.98	52.46		
0	1.52	5.97	91.34	29.89	21.45		
5	2.63	20.73	82.23	61.70	77.01		
10	2.31	24.9	82.30	72.30	70.66		
15	1.91	18.96	83.68	54.69	75.52		
20	2.08	20.90	72.64	40.83	67.83		

	Convers	ion (%)	Power consumption (Ws x 10 <sup>16</sup> )		
Ag loading (wt.%)	C <sub>2</sub> H <sub>4</sub>	H <sub>4</sub> O <sub>2</sub> per molecule conver		per molecule of EO produced	
Sole plasma	21.79	91.51	1.42	14.06	
0	15.62	94.27	2.30	20.64	
5	23.13	98.49	1.31	18.64	
10	18.35	95.19	1.58	14.11	
15	17.00	62.94	1.91	23.57	
20	7.00	64.36	4.66	15.26	
25	10.25	42.79	2.16	18.59	
30	12.08	37.89	1.79	11.96	

**Table A5** Effect of Ag loading on the  $SiO_2$  support on  $C_2H_4$  and  $O_2$  conversions, and power consumption

**Table A6** Effect of Ag loading on the  $SiO_2$  support on EO yield and selectivities forEO and other products

Ag loading (wt.%)	EO yield	Selectivity <sup>*</sup> (%)				
	(%)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	
Sole plasma	2.20	10.08	79.28	60.98	52.46	
0	1.74	11.12	73.52	69.66	62.28	
5	1.62	7.00	48.01	19.96	38.39	
10	2.06	11.23	32.93	24.67	4.30	
15	1.33	8.04	4035	19.65	28.64	
20	2.10	30.56	61.54	29.62	49.49	
25	1.75	17.11	16.64	17.72	48.80	
30	1.81	15.00	15.52	12.00	77.53	

**Table A7** Comparisons of the ethylene epoxidation performances in terms of  $C_2H_4$  and  $O_2$  conversions, and power consumption under the sole DBD system, the DBD system with the unloaded supports and the DBD system with both supported Ag catalysts

	Conversion (%)		Power consumption (Ws x 10 <sup>16</sup> )		
DDD system	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	per molecule of $C_2H_4$ converted	per molecule of EO produced	
Sole DBD	21.79	91.51	1.42	14.06	
With Al <sub>2</sub> O <sub>3</sub> support	25.42	97.68	1.03	17.33	
With SiO <sub>2</sub> support	15.62	94.22	2.30	20.64	
With 10 wt.% Ag/Al <sub>2</sub> O <sub>3</sub> support	9.28	57.69	3.50	14.07	
With 20 wt.% Ag/SiO2 support	7.00	64.36	4.66	15.26	

**Table A8** Comparisons of the ethylene epoxidation performances in terms of EOyield and selectivities for EO and other products under the sole DBD system, theDBD system with the unloaded supports and the DBD system with both supportedAg catalysts

DBD system	EO yield	Selectivity <sup>*</sup> (%)				
	(%)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	
Sole DBD	2.20	10.08	79.28	60.98	52.46	
With Al <sub>2</sub> O <sub>3</sub> support	1.52	5.97	91.34	29.89	21.45	
With SiO <sub>2</sub> support	1.74	11.12	73.52	69.60	62.28	
With 10 wt.% Ag/Al <sub>2</sub> O <sub>3</sub> support	2.31	24.93	82.30	72.30	70.66	
With 20 wt.% Ag/SiO2 support	2.14	30.56	61.56	29.69	49.49	

## Appendix B Ethylene Epoxidation in Cylindrical Dielectric Barrier Discharge: Effects of Separate Ethylene/Oxygen Feed

**Table B1** Effect of  $C_2H_4$  feed position on  $C_2H_4$  and  $O_2$  conversions, and power consumption

C II food position	Conversion (%)		Power consumption (Ws x $10^{16}$ )		
$C_2H_4$ leed position	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced	
Mixed feed	10.62	62.62	1.53	6.26	
0	10.17	62.93	1.50	6.82	
0.25	2.89	60.15	6.32	8.04	
0.50	6.82	36.63	2.37	12.40	
0.75	4.77	28.83	3.34	-	
1	2.11	26.05	7.50	-	

**Table B2** Effect of  $C_2H_4$  feed position on EO yield, current, and selectivities for EO and other products

C <sub>2</sub> H <sub>4</sub> feed position	EO yield Curren		Selectivity ** (%)				
	(%)	(mA)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	
Mixed feed	2.60	0.72	8.94	23.96	24.83	37.96	
0	2.32	0.75	12.65	22.84	26.97	34.16	
0.25	2.08	0.76	15.06	20.64	31.45	27.94	
0.50	1.30	0.77	17.02	20.19	39.05	23.74	
0.75	0	0.76	0	0	70.54	25.27	
1	0	0.74	0	0	83.68	7.33	

C <sub>2</sub> H <sub>4</sub> feed	Concentration of outlet gas (mol%)							
position	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	EO	H <sub>2</sub>	CO	C <sub>2</sub> H <sub>2</sub>		
Mixed feed	14.75	1.61	0.47	1.25	1.30	1.98		
0	16.18	1.68	0.42	0.75	0.89	1.13		
0.25	17.39	1.73	0.37	0.51	0.78	0.72		
0.50	16.68	2.62	0.23	0.28	0.53	0.32		
0.75	17.45	3.15	0	0	0.41	0.15		
]	17.65	3.25	0	0	0.34	0.04		

Table B3 Effect of  $C_2H_4$  feed position on concentration of outlet gas

**Table B4** Effect of  $O_2/C_2H_4$  Feed Molar Ratio on  $C_2H_4$  and  $O_2$  conversions, and power consumption

O <sub>2</sub> /C <sub>2</sub> H <sub>4</sub> Feed Molar	eed Molar Conversion (%)		Power consumption (Ws x 10 <sup>16</sup> )		
Ratio	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	per molecule of $C_2H_4$ converted	per molecule of EO produced	
1/5	3.29	58.86	4.78	9.20	
1/4	2.89	60.15	6.32	8.04	
1/3.33	3.23	78.50	4.77	7.60	
1/2.25	2.58	42.82	5.68	9.34	
1/2	3.16	60.45	5.49	10.96	
1/0.67	8.92	28.91	1.67	9.86	

$O_2/C_2H_4$ Feed Molar	EO yield		Selectivi	ity ** (%)	
Ratio	(%)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>
1/5	1.71	16.11	17.95	29.70	33.68
1/4	2.08	15.06	20.64	31.45	27.94
1/3.33	1.92	11.92	18.32	29.42	36.65
1/2.25	1.57	12.39	18.72	33.37	31.33
1/2	1.55	11.81	17.31	32.68	35.01
1/0.67	1.51	11.86	22.48	38.42	24.16

**Table B5** Effect of  $O_2/C_2H_4$  Feed Molar Ratio on EO yield and selectivities for EO and other products

Table B6 Effect of O<sub>2</sub>/C<sub>2</sub>H<sub>4</sub> Feed Molar Ratio on concentration of outlet gas

$O_2/C_2H_4$ Feed	Concentration of outlet gas (mol%)							
Molar Ratio	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	EO	H <sub>2</sub>	СО	$C_2H_2$		
1/5	14.75	0.04	0.47	1.25	1.30	1.98		
1/4	16.18	1.68	0.42	0.75	0.89	1.13		
1/3.33	17.39	1.73	0.37	0.51	0.78	0.72		
1/2.25	16.68	2.62	0.23	0.25	0.53	0.32		
1/2	17.45	3.15	0	0	0.41	0.15		
1/0.67	17.65	3.25	0	0	0.34	0.04		

Applied voltage (I(X))	Conversion (%)		Power consumption (Ws x 10 <sup>16</sup> )		
Applied voltage (k v )	$C_2H_4$	O <sub>2</sub>	per molecule of $C_2H_4$ converted	per molecule of EO produced	
12	5.12	99.28	2.36	5.60	
13	4.60	99.83	3.12	5.03	
14	3.34	99.47	3.64	5.36	
15	2.89	60.14	6.32	8.04	
17	4.81	55.96	3.15	6.68	

Table B7 Effect of applied voltage on  $C_2H_4$  and  $O_2$  conversions, and power consumption

**Table B8** Effect of applied voltage on EO yield, current, and selectivities for EOand other products

Applied voltage (kV)	EO yield	Current		selectivity <sup>**</sup> (%)			
	(%)	(mA)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	
12	4.06	0.720	22.52	28.37	13.45	32.87	
13	7.98	0.743	30.57	17.11	12.48	36.09	
14	4.56	0.751	22.04	27.88	14.39	32.59	
15	2.08	0.764	15.06	20.64	31.45	27.94	
17	2.30	0.770	15.96	16.13	29.23	35.35	

Applied voltage	Concentration of outlet gas (mol%)						
(kV)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	EO	H <sub>2</sub>	СО	$C_2H_2$	
12	21.89	0.03	.94	1.18	0.56	1.37	
13	18.93	0.01	1.58	0.89	0.65	1.87	
14	22.52	0.03	1.06	1.35	0.69	1.57	
15	17.39	1.73	0.37	0.51	0.78	0.72	
17	19.22	1.99	0.46	0.47	0.85	1.03	

Table B9 Effect of applied voltage on concentration of outlet gas

Table B10 Effect of input frequency on  $C_2H_4$  and  $O_2$  conversions, and power consumption

	Convers	ion (%)	Power consumption (Ws x 10 <sup>16</sup> )		
Input Irequency (Hz)	C₂H₄	O <sub>2</sub>	per molecule of $C_2H_4$ converted	per molecule of EO produced	
450	2.28	45.25	5.63	7.73	
500	4.60	99.83	3.12	5.03	
550	3.68	74.57	3.49	5.21	
600	2.91	29.34	1.95	13.24	

**Table B11** Effect of input frequency on EO yield, current, and selectivities for EO and other products

Input frequency (Hz)	EO yield	Current	Selectivity <sup>**</sup> (%)			
	(%)	(mA)	EO	H <sub>2</sub>	СО	$C_2H_2$
450	1.66	0.758	19.38	24.51	47.82	5.09
500	7.98	0.743	30.57	17.11	12.48	36.09
550	7.47	0.728	33.85	13.35	5.42	42.53
600	0.79	0.687	13.54	16.53	42.63	23.64

Input frequency	Concentration of outlet gas (mol%)							
(Hz)	$C_2H_4$	O <sub>2</sub>	EO	H <sub>2</sub>	CO	C <sub>2</sub> H <sub>2</sub>		
450	22.28	2.69	0.38	0.48	0.93	0.10		
500	18.93	0.01	1.58	0.89	0.65	1.87		
550	21.80	1.18	1.69	0.67	0.27	2.12		
600	23.52	3.16	0.19	0.23	0.60	0.33		

Table B12 Effect of input frequency on concentration of outlet gas

**Table B13** Effect of total feed flow rate on  $C_2H_4$  and  $O_2$  conversions, and power consumption

Total feed flow rate	Conversion (%)C2H4O2		Power consumption (Ws x 10 <sup>16</sup> )		
(cm <sup>3</sup> /min)			per molecule of $C_2H_4$ converted	per molecule of EO produced	
60	5.59	41.48	2.21	8.69	
75	3.68	74.57	3.49	5.21	
100	8.05	45.62	1.03	7.13	
125	3.12	17.35	2.17	12.29	

**Table B14** Effect of total feed flow rate on EO yield, current, and selectivities forEO and other products

Total feed flow rate	EO yield	EO yield Current		Selectivity <sup>**</sup> (%)				
(cm <sup>3</sup> /min)	(%)	(mA)	EO	H <sub>2</sub>	СО	$C_2H_2$		
60	1.42	0.702	17.67	25.92	34.13	20.23		
75	7.47	0.756	33.85	13.35	5.42	42.53		
100	1.16	0.718	21.82	0.00	42.15	35.32		
125	0.55	0.705	13.68	0.00	25.58	57.65		

Total feed flow	Concentration of outlet gas (mol%)							
rate (cm <sup>3</sup> /min)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	EO	H <sub>2</sub>	СО	$C_2H_2$		
60	24.84	1.30	0.37	0.55	0.72	0.43		
75	21.80	1.18	1.69	0.67	0.27	2.12		
100	22.16	1.74	0.28	0.00	0.54	0.45		
125	23.01	2.91	0.13	0.00	0.24	0.55		

Table B15 Effect of total feed flow rate on concentration of outlet gas

**Table B16** Comparisons of the cylindrical DBD system performance using the separate  $C_2H_4/O_2$  feed and the mixed  $C_2H_4/O_2$  feed in terms of  $C_2H_4$  and  $O_2$  conversions, and power consumption

	Convers	sion (%)	Power consumption (Ws x $10^{16}$ )		
DBD system	$C_2H_4$ $O_2$		per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced	
Separate feed	3.68	74.57	3.49	5.21	
Mixed feed	10.62	62.93	1.50	6.30	

**Table B17** Comparisons of the cylindrical DBD system performance using the separate  $C_2H_4/O_2$  feed and the mixed  $C_2H_4/O_2$  feed in terms of EO yield and selectivities for EO and other products

DBD system	EO yield (%)	Selectivity <sup>**</sup> (%)				
		EO	H <sub>2</sub>	СО	$C_2H_2$	
Separate feed	7.47	33.85	13.35	5.42	42.52	
Mixed feed	2.60	8.90	24.00	24.80	38.00	

## Appendix C Ethylene Epoxidation in a Low-Temperature Corona Discharge System: Effect of Separate Ethylene/Oxygen Feed

**Table C1** Effect of  $C_2H_4$  feed position on  $C_2H_4$  and  $O_2$  conversions, EO yield, and power consumption

$C_2H_4$ feed Conversion (%)		ion (%)	EO vield	Power consumption (Ws x 10 <sup>16</sup> )			
position	C₂H₄	O <sub>2</sub>	(%)	per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced		
Mixed feed	14.19	39.57	0.63	1.82	40.94		
0.1	4.21	29.62	0.46	2.78	25.20		
0.2	2.35	25.98	0.68	4.88	16.84		
0.3	4.50	26.05	0.64	2.61	18.22		
0.4	6.21	31.85	0.46	1.87	25.47		
0.5	6.59	27.95	0.48	1.76	23.94		
0.7	3.90	26.54	0.40	3.05	29.45		

Table C2 Effect of C<sub>2</sub>H<sub>4</sub> feed position on selectivities for EO and other products

C <sub>2</sub> H <sub>4</sub> feed position			Selectivity	* (%)		
-2 F	EO	H <sub>2</sub>	СО	$C_2H_2$	$C_3H_8$	CH <sub>4</sub>
Mixed feed	2.95	0	48.15	10.51	2.16	35.84
0.1	2.04	30.26	44.46	15.10	1.79	6.35
0.2	3.83	28.85	42.85	15.47	2.29	6.71
0.3	3.02	28.58	43.57	16.80	2.09	5.94
0.4	2.11	27.51	46.36	15.75	1.97	6.30
0.5	2.38	28.62	43.48	16.79	2.05	6.68
0.7	1.79	29.35	44.96	15.99	1.87	6.04

O <sub>2</sub> /C <sub>2</sub> H <sub>4</sub>	Convers	sion (%)	EQuiald	Power consumption (Ws x 10 <sup>16</sup> )				
feed molar ratio	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	(%)	per molecule of C₂H₄ converted	per molecule of EO produced			
0.25:1	3.38	39.04	0.40	3.10	26.31			
0.33:1	1.25	20.01	0.51	7.90	19.24			
0.5:1	2.35	25.98	0.68	4.88	16.84			
0.75:1	4.18	33.91	0.57	2.35	17.39			
1:1	3.60	30.69	0.06	3.02	187.15			

**Table C3** Effect of  $O_2/C_2H_4$  feed molar ratio on  $C_2H_4$  and  $O_2$  conversions, EO yield, and power consumption

Table C4 Effect of  $O_2/C_2H_4$  feed molar ratio on selectivities for EO and other products

$O_2/C_2H_4$ feed molar	Selectivity <sup>**</sup> (%)										
ratio	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	C <sub>3</sub> H <sub>8</sub>	CH₄					
0.25:1	2.60	27.00	48.85	13.43	1.95	6.16					
0.33:1	4.32	28.75	38.89	18.68	2.96	6.40					
0.5:1	3.83	28.85	42.85	15.47	2.29	6.71					
0.75:1	2.25	18.09	47.85	20.73	2.53	8.55					
1:1	0.26	23.71	65.72	4.15	0.47	5.69					

Applied voltage	Conv (º	ersion ‰)	EO yield	Power consumption (Ws x 10 <sup>16</sup> )			
(KV)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	(%)	per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced		
15	2.35	25.98	0.68	4.88	16.84		
16	2.43	36.92	1.12	4.34	9.42		
17	2.24	39.82	1.34	4.34	7.26		
18	2.25	44.33	1.76	4.74	6.07		
19	2.00	47.82	0.90	5.10	11.27		

Table C5 Effect of applied voltage on  $C_2H_4$  and  $O_2$  conversions, EO yield, and power consumption

Applied voltage	Current	Selectivity <sup>**</sup> (%)								
(kV)	(mA)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	C <sub>3</sub> H <sub>8</sub>	CH₄			
15	0.718	3.83	28.85	42.85	15.47	2.29	6.71			
16	0.718	6.08	26.17	48.79	11.04	1.28	6.63			
17	0.720	6.82	24.31	51.50	10.71	1.28	5.37			
18	0.724	8.42	26.63	45.85	10.99	1.33	6.77			
19	0.729	4.61	33.28	35.47	16.78	2.62	7.24			

Input frequency Conve	rsion (%)	EO	Power consumption (Ws x 10 <sup>16</sup> )			
(Hz)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	yield (%)	per molecule of $C_2H_4$ converted	per molecule of EO produced	
400	3.95	60.26	0.83	2.62	12.49	
500	2.25	44.33	1.76	4.74	6.07	
600	2.03	32.55	1.19	4.69	7.98	
700	1.77	22.56	1.06	5.00	8.37	

Table C7 Effect of input frequency on  $C_2H_4$  and  $O_2$  conversions, EO yield, and power consumption

 Table C8 Effect of input frequency on current and selectivities for EO and other

 products

Input frequency	Current	Selectivity <sup>**</sup> (%)								
(Hz)	(mA)	EO	H <sub>2</sub>	CO	$C_2H_2$	C <sub>3</sub> H <sub>8</sub>	CH₄			
400	0.768	3.03	27.11	43.11	14.70	2.26	9.80			
500	0.724	8.42	26.63	45.85	10.99	1.33	6.77			
600	0.711	7.29	23.25	53.35	9.36	1.04	5.70			
700	0.679	6.65	27.31	39.94	18.19	1.80	6.11			

Table C9	Effect	of total	feed	flow	rate	on	$C_2H_4$	and	$O_2$	conversions	and	power
consumptio	n											

Total feed flow	Residence	Convers	sion (%)	Power consumption (Ws x 10 <sup>16</sup> )			
rate (cm <sup>3</sup> /min)	time (s)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	per molecule of $C_2H_4$ converted	per molecule of EO produced		
100	0.077	2.25	44.33	4.74	6.07		
125	0.062	1.41	34.04	7.03	18.53		
150	0.051	1.70	31.78	5.56	30.74		

Total feed flow	EO yield	Selectivity <sup>**</sup> (%)							
rate (cm <sup>3</sup> /min)	(%)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	C <sub>3</sub> H <sub>8</sub>	CH4		
100	1.76	8.42	26.63	45.85	10.99	1.33	6.77		
125	0.54	3.20	31.18	47.02	10.30	1.13	7.17		
150	0.31	2.00	28.91	47.89	11.78	2.25	7.17		

 Table C10 Effect of total feed flow rate on EO yield and selectivities for EO and other products

Table C11 Effect of electrode gap distance on  $C_2H_4$  and  $O_2$  conversions and power consumption

Electrode gap	Residence	Conversion (%)		Power consumption (Ws x 10 <sup>16</sup> )		
distance (cm)	time (s)	$C_2H_4$	O <sub>2</sub>	per molecule of $C_2H_4$ converted	per molecule of EO produced	
0.8	0.062	1.83	42.30	4.92	6.88	
0.9	0.069	1.85	48.20	4.85	6.44	
1.0	0.077	2.25	44.33	4.74	6.07	
1.1	0.085	1.91	41.19	5.18	10.03	
1.2	0.092	4.34	54.34	2.14	13.12	

**Table C12** Effect of electrode gap distance on EO yield, current, and selectivitiesfor EO and other products

Electrode gap	EO yield	Current	Selectivity <sup>**</sup> (%)					
distance (cm)	(%)	(mA)	EO	H <sub>2</sub>	СО	C <sub>2</sub> H <sub>2</sub>	C <sub>3</sub> H <sub>8</sub>	CH₄
0.8	1.31	0.728	9.19	30.16	37.23	13.26	3.03	7.13
0.9	1.39	0.726	8.41	27.57	47.88	7.38	1.26	7.50
1.0	1.76	0.724	8.42	26.63	45.85	10.99	1.33	6.77
1.1	0.99	0.723	4.90	28.09	56.63	1.40	1.08	7.90
1.2	0.71	0.721	3.36	26.97	54.34	8.18	0.90	6.26

**Table C13** Comparisons of the corona discharge performance using the separate and the mixed  $C_2H_4/O_2$  feed in terms of  $C_2H_4$  and  $O_2$  conversions, and power consumption

DPD system	Conver	sion (%)	Power consumption (Ws x 10 <sup>16</sup> )		
DBD system	C <sub>2</sub> H <sub>4</sub> O <sub>2</sub>		per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced	
Mixed feed	14.19	39.54	1.82	40.94	
Separate feed	2.25	44.33	4.74	6.07	

**Table C14** Comparisons of the corona discharge performance using the separate and the mixed  $C_2H_4/O_2$  feed in terms of EO yield and selectivities for EO and other products

DBD system	EQ vield (%)	Selectivity <sup>**</sup> (%)					
	EO yleid (76)	EO	СО	C <sub>2</sub> H <sub>2</sub>	CH4	$C_3H_8$	
Mixed feed	0.63	2.95	48.15	10.51	35.84	2.16	
Separate feed	1.76	8.42	45.85	10.99	6.77	1.33	

# Appendix D Ethylene Epoxidation in an AC Dielectric Barrier Discharge Jet System

Table D1	Effect of to	otal feed	flow rat	e on	$C_2H_4$	and	O <sub>2</sub>	conversions	and	power
(	consumption	1								

Total feed flow Residence		Convers	sion (%)	Power consumption (Ws x $10^{21}$ )		
rate (cm <sup>3</sup> /min)	time (s x 100)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	per molecule of $C_2H_4$ converted	per molecule of EO produced	
1,625	2.29	41.04	75.14	3.77	11.36	
1,896	1.96	33.30	70.15	4.52	16.08	
2,167	1.72	35.00	56.69	4.75	15.07	
2,438	1.53	37.56	55.33	4.55	16.73	
2,708	1.37	38.09	48.83	5.43	20.97	
3,250	1.14	38.91	48.14	5.94	25.73	

 Table D2
 Effect of total feed flow rate on EO yield and selectivities for EO and other products

Total feed flow	EO yield	Selectivity (%)					
rate (cm <sup>3</sup> /min)	(%)	EO	H <sub>2</sub>	CO	CH₄	C <sub>2</sub> H <sub>6</sub>	
1,625	13.63	33.22	34.81	3.87	0.52	0.02	
1,896	11.10	33.32	29.29	3.74	2.47	0.08	
2,167	11.03	31.50	27.33	4.52	2.79	0.14	
2,438	10.21	27.19	22.99	3.64	0.20	0.09	
2,708	9.86	25.90	18.21	5.13	2.06	0.10	
3,250	8.98	23.08	13.93	10.66	0.26	0.11	

Total feed flow	Current	Formation (%)		
rate (cm <sup>3</sup> /min)	(mA)	Coke	Water	
1,625	0.523	25.57	12.66	
1,896	0.532	20.10	10.75	
2,167	0.521	21.37	12.38	
2,438	0.521	25.87	18.51	
2,708	0.520	25.45	19.66	
3,250	0.511	25.63	24.24	

 Table D3 Effect of total feed flow rate on current and coke and water formations

**Table D4** Effect of  $O_2/C_2H_4$  feed molar ratio on  $C_2H_4$  and  $O_2$  conversions, EO yield,and power consumption

$O_2/C_2H_4$	Conversion (%)		EQuiald	Power consumption (Ws x $10^{21}$ )		
teed molar ratio	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	(%)	per molecule of $C_2H_4$ converted	per molecule of EO produced	
0.20:1	29.39	67.32	7.62	8.80	33.96	
0.25:1	41.04	75.14	13.63	6.07	18.29	
0.30:1	47.30	73.54	7.85	6.51	39.24	
0.40:1	42.18	81.42	5.39	5.35	41.85	
0.50:1	44.23	87.66	6.77	4.36	28.45	

Table D5 Effect of  $O_2/C_2H_4$  feed molar ratio on selectivities for EO and other products

$O_2/C_2H_4$ feed molar	Selectivity <sup>*</sup> (%)							
ratio	EO	H <sub>2</sub>	СО	CH₄	C <sub>2</sub> H <sub>6</sub>			
0.20:1	25.91	44.22	2.08	0.96	0.05			
0.25:1	33.22	34.81	3.87	0.52	0.02			
0.30:1	16.60	27.09	5.32	0.28	0.02			
0.40:1	12.79	29.59	9.53	0.09	0.03			
0.50:1	15.32	51.90	34.13	0.00	0.02			

$O_2/C_2H_4$ feed molar	Current	Format	tion (%)
ratio	(mA)	Coke	Water
0.20:1	0.520	20.86	8.18
0.25:1	0.523	25.57	12.66
0.30:1	0.530	36.79	26.35
0.40:1	0.511	32.71	24.20
0.50:1	0.518	22.35	14.49

**Table D6** Effect of  $O_2/C_2H_4$  feed molar ratio on current and coke and water formations

**Table D7** Effect of applied voltage on C2H4 and O2 conversions, EO yield, andpower consumption

Applied	Convers	sion (%)	EO vield	Power consumption (Ws x $10^{21}$ )		
voltage (kV)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	(%)	per molecule of C <sub>2</sub> H <sub>4</sub> converted	per molecule of EO produced	
7	41.04	75.14	13.63	6.18	18.61	
8	45.99	73.93	17.71	5.13	13.31	
9	44.83	75.41	18.41	5.15	12.55	
10	43.98	76.04	14.87	6.37	18.85	
11	47.76	80.48	11.91	5.93	23.76	
13	46.56	82.52	11.52	6.50	26.26	
15	44.53	85.13	7.94	7.22	40.51	

Applied voltage	selectivity (%)					
(kV)	EO	H <sub>2</sub>	СО	CH₄	C <sub>2</sub> H <sub>6</sub>	
7	33.22	34.81	3.87	0.52	0.02	
8	38.51	34.85	4.67	0.51	0.01	
9	41.06	39.09	5.48	0.47	0.02	
10	33.81	44.72	6.67	0.52	0.02	
11	24.95	44.10	7.03	0.50	0.01	
13	24.74	48.14	7.95	0.51	0.03	
15	17.83	59.08	9.04	0.42	0.02	

Table D8 Effect of applied voltage on selectivities for EO and other products

\* Selectivity based on C<sub>2</sub>H<sub>4</sub> conversion

 Table D9
 Effect of applied voltage on power, current, and coke and water

 formations

Applied voltage	Power	Current	Formati	on (%)
(kV)	(W)	(mA)	Coke	Water
7	0.074	0.523	25.57	12.66
8	0.082	0.643	25.88	11.76
9	0.081	0.676	23.73	8.45
10	0.091	0.750	25.94	8.97
11	0.101	0.825	32.23	14.29
13	0.111	0.978	31.09	12.13
15	0.117	1.100	32.36	9.89

Input	Convers	sion (%)	EQuiald	Power consumption (Ws x $10^{21}$ )		
frequency (Hz)	C₂H₄	O <sub>2</sub>	(%)	per molecule of $C_2H_4$ converted	per molecule of EO produced	
300	42.01	93.12	19.20	0.817	1.788	
400	42.01	78.92	17.23	2.544	6.204	
500	44.83	75.41	18.41	5.153	12.550	
600	41.58	62.86	12.44	17.093	57.138	
700	43.85	66.90	11.29	26.892	104.446	
800	42.36	64.30	9.54	30.695	136.320	
900	46.06	56.76	7.64	36.978	222.783	

Table D10 Effect of input frequency on  $C_2H_4$  and  $O_2$  conversions, EO yield, and power consumption

Table D11 Effect of input frequency on selectivities for EO and other products

Input frequency	Selectivity (%)				
(Hz)	EO	H <sub>2</sub>	СО	CH4	C <sub>2</sub> H <sub>6</sub>
300	45.71	8.75	1.66	0.14	0.04
400	41.00	16.89	2.55	0.19	0.02
500	41.06	39.09	5.48	0.47	0.02
600	29.92	47.04	6.40	0.51	0.03
700	25.75	51.19	10.29	0.49	0.02
800	22.52	52.08	10.31	0.47	0.01
900	16.60	57.36	8.16	0.52	0.01

Input frequency	Power	Current	Formati	on (%)
(Hz)	(W)	(mA)	Coke	Water
300	0.012	0.447	22.03	18.99
400	0.034	0.566	23.63	17.52
500	0.081	0.676	23.73	8.45
600	0.263	0.798	26.25	9.14
700	0.304	0.938	27.82	9.66
800	0.383	1.070	28.25	10.36
900	0.593	1.170	34.41	11.51

 Table D12
 Effect of input frequency on power, current, and coke and water

 formations

**Table D13** Effect of Spacing of inner pin electrode and  $C_2H_4$  feed point on  $C_2H_4$ and  $O_2$  conversions, EO yield, and power consumption

Spacing	Convers	sion (%)	EO vield	EO vield Power consumption (Ws	
(mm)	C <sub>2</sub> H <sub>4</sub>	O <sub>2</sub>	(%)	per molecule of $C_2H_4$ converted	per molecule of EO produced
0	42.01	93.12	19.20	2.96	6.47
3	49.95	91.23	27.57	3.33	6.03
6	21.99	93.49	7.30	10.47	31.53

**Table D14** Effect of Spacing of inner pin electrode and  $C_2H_4$  feed point onselectivities for EO and other products

Spacing		Se	lectivity <sup>*</sup> (	%)	
(mm)	EO	H <sub>2</sub>	СО	CH4	C <sub>2</sub> H <sub>6</sub>
0	45.71	8.75	1.66	0.14	0.04
3	55.19	4.04	0.66	0.07	0.01
6	33.20	2.77	0.43	0.07	0.06

Spacing	Power	Current	Formati	on (%)
(mm)	(W)	(mA)	Coke	Water
0	0.0424	0.447	22.03	18.99
3	0.0438	0.441	22.01	20.28
6	0.0471	0.441	14.56	14.03

**Table D15** Effect of Spacing of inner pin electrode and  $C_2H_4$  feed point on power, current, and coke and water formations

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